



EAST WEST UNIVERSITY

Course Title:Electrical Circuits

Course:CSE251

Lab Report (6)

Section: 5

Date: 12.1.22

Experiment Title: Measurement of Parameters and I-V characteristics of an N-channel MOSFET.

Submitted by:

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Title: Measurement of Parameters and I-V characteristics of an N-channel MOSFET.

Objectives:

1. To measure the threshold voltage V_t and the process transconductance K_n of an N-channel enhancement type MOSFET.
2. To measure the I-V characteristics (I_D vs. V_{DS}) of an N-channel enhancement type MOSFET.

Circuit Diagram:

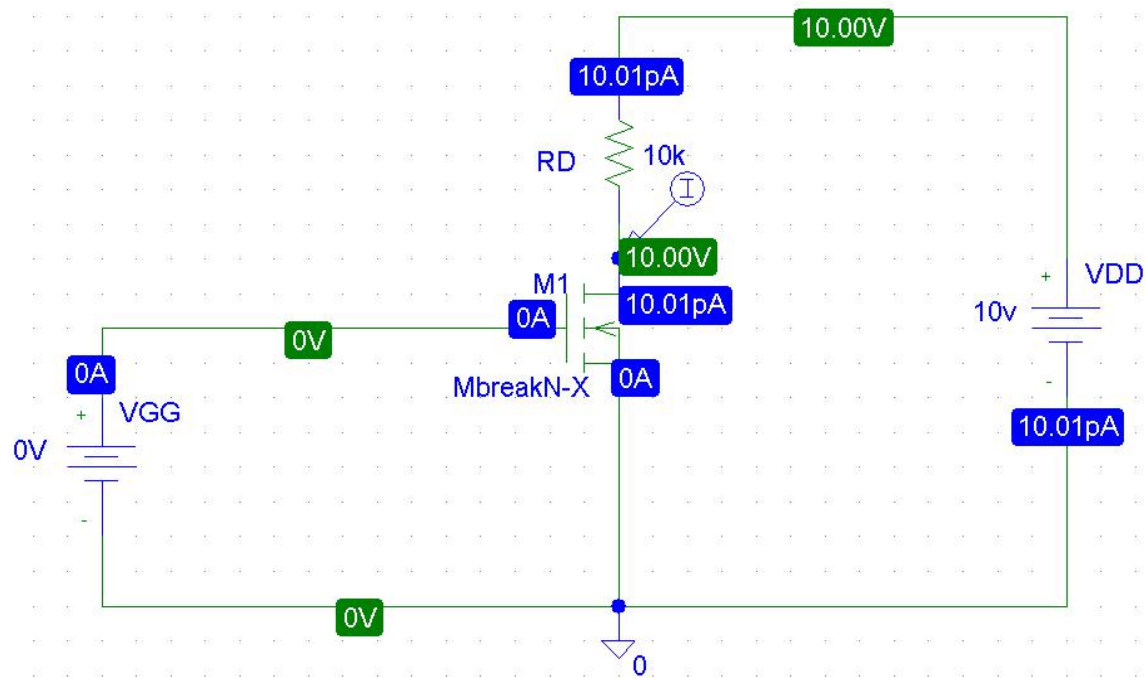


Fig: N-channel MOSFET

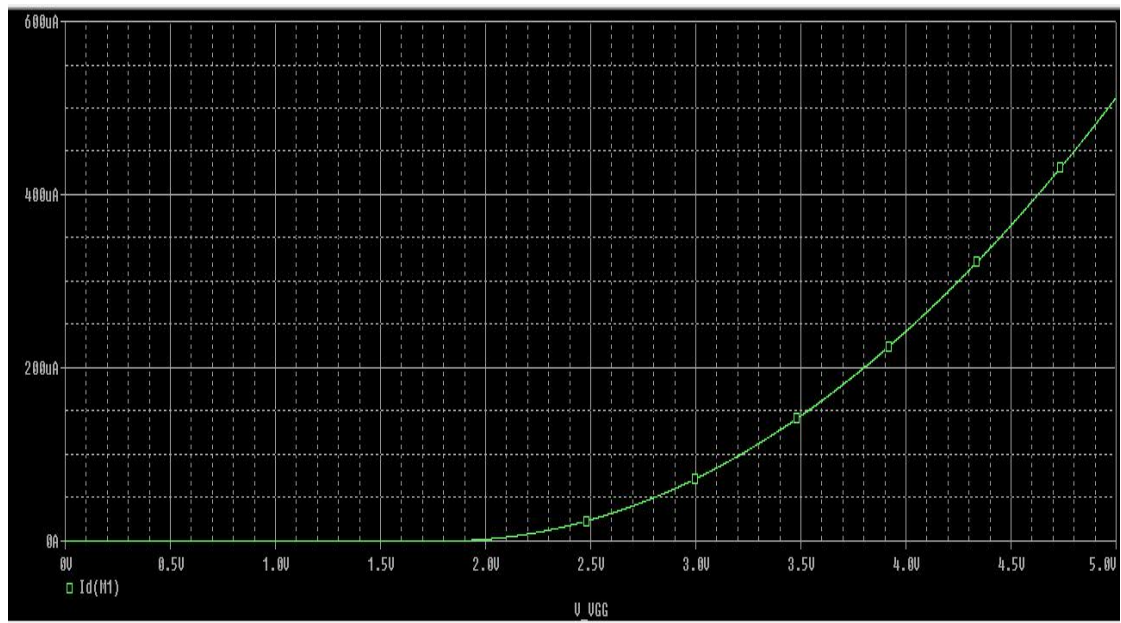


Fig: ID-VGS Characteristics

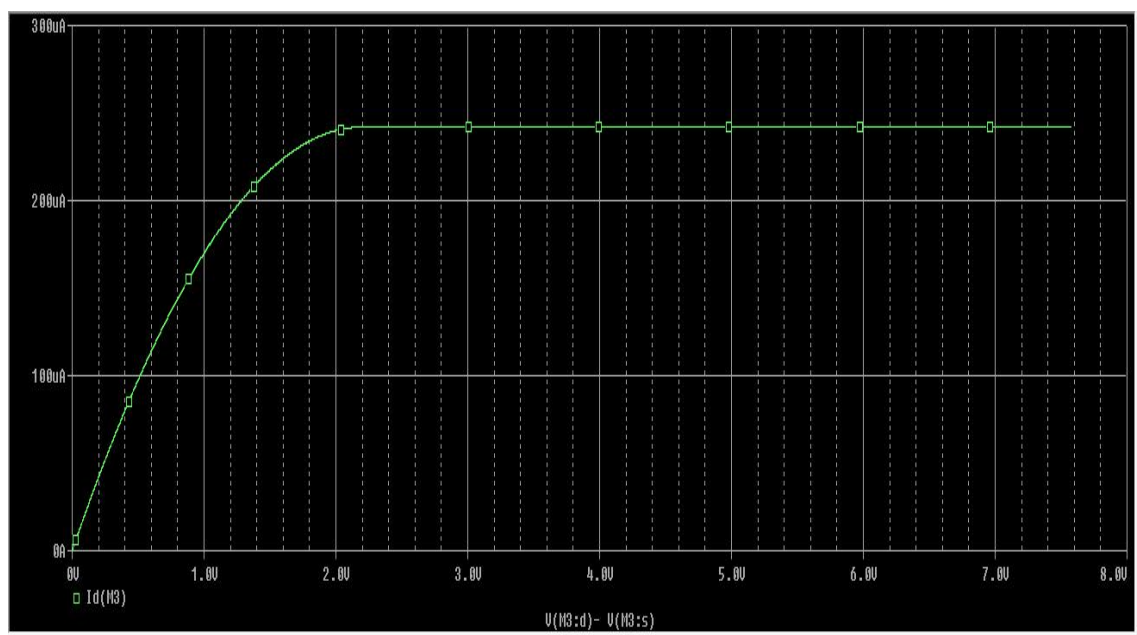


Fig: ID-VDS Characteristics

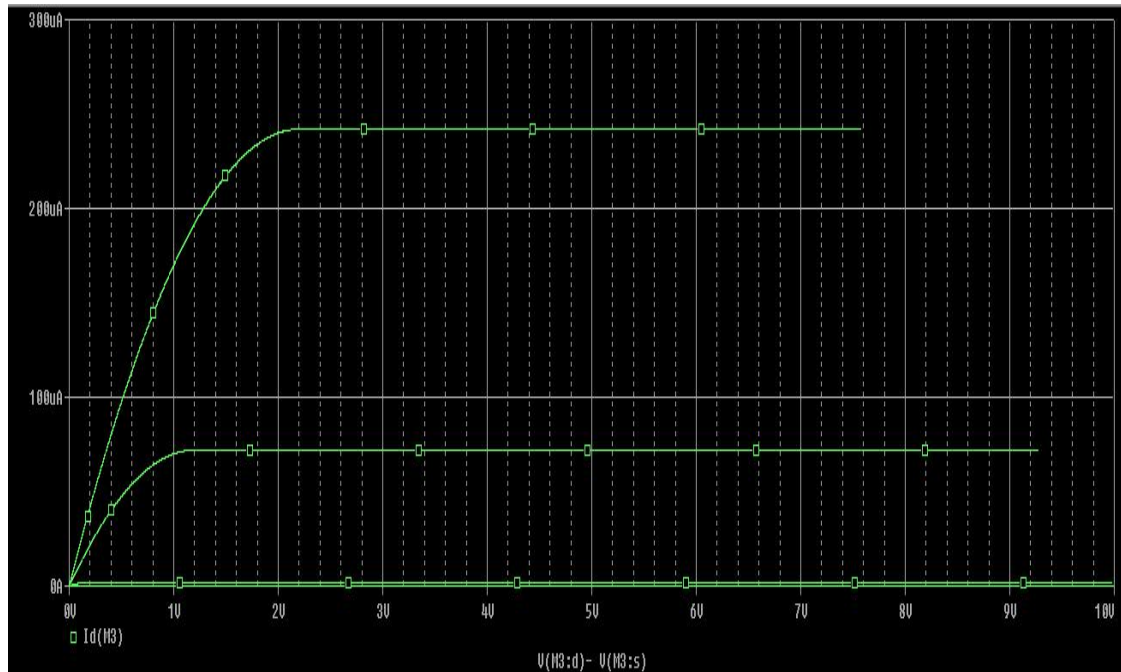
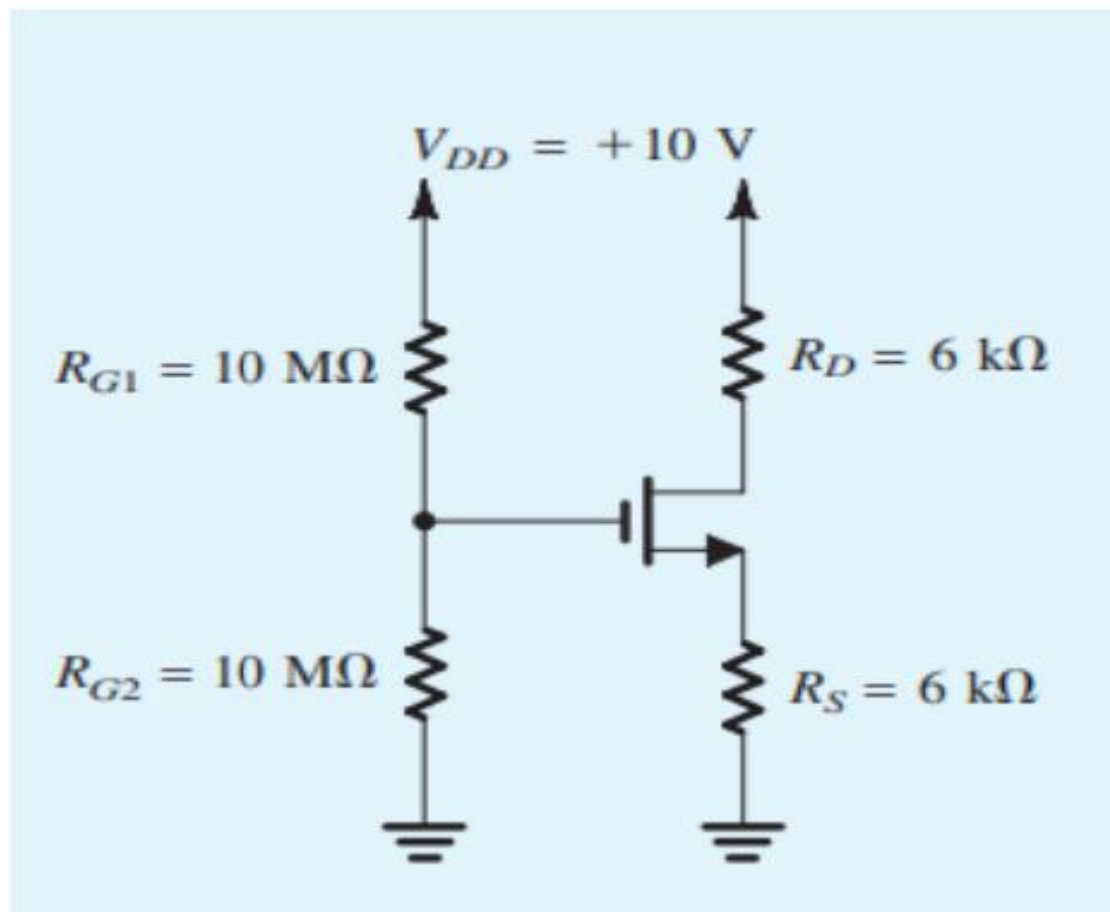


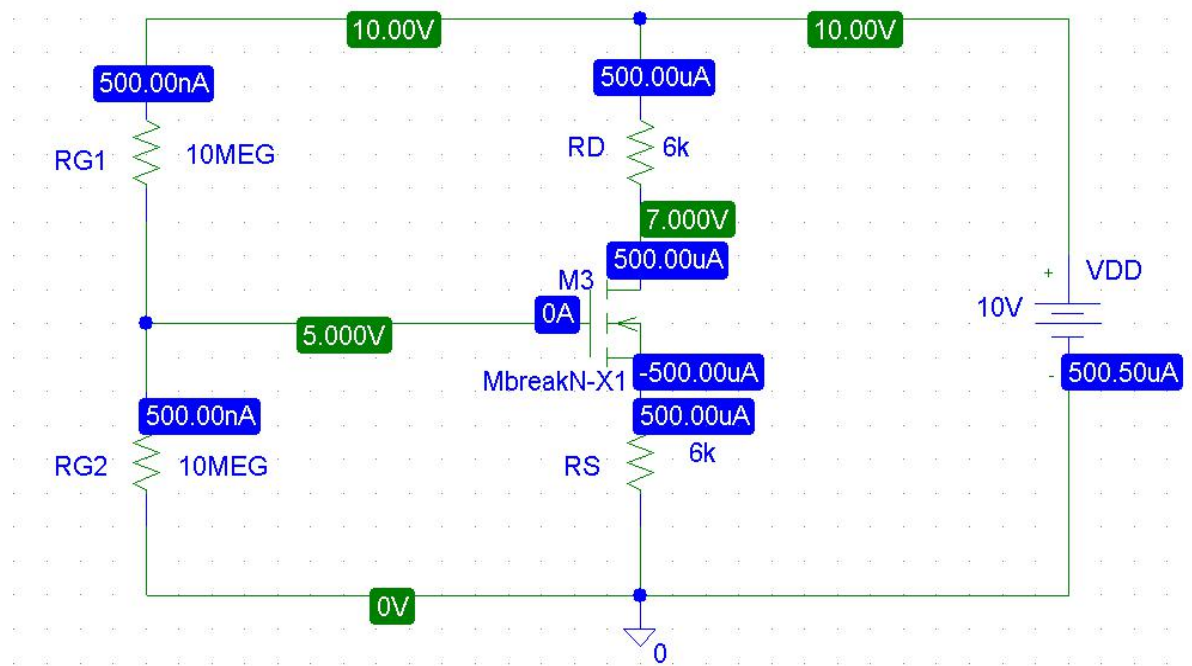
Fig: ID-VDS Characteristics for multiple VGS

Simulation of a MOSFET dc circuit from textbook:

Reference:



Simulation:



Conclusion:

From this experiment, we have learnt N-MOS characteristics and I_d - V_{gs} Characteristics, I_d - V_{ds} Characteristics of a circuits.